



JPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Toru YAMADA

Group Art Unit: 1722

Application No.: 10/582,802

Docket No.: 136170

Filed: June 14, 2006

For: VAPOR PHASE GROWTH APPARATUS AND METHOD OF FABRICATING
EPITAXIAL WAFER

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
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Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

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RRS:scg

Date: February 13, 2008

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/582,802	06/14/2006	1722	900	SUG 192-PCT 136170	13	15	2

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 Washington, DC 20038-7613



CONFIRMATION NO. 7018

FILING RECEIPT



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Applicant(s)

Toru Yamada, Gunma, JAPAN;

Power of Attorney: The patent practitioners associated with Customer Number 28892.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/17193 11/18/2004

Foreign Applications

JAPAN

~~UNITED KINGDOM~~ 2003-419201 12/17/2003

If Required, Foreign Filing License Granted: 02/08/2007

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/582,802**

Projected Publication Date: 05/17/2007

Non-Publication Request: No

Early Publication Request: No

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Vapor phase growth apparatus and method of fabricating epitaxial wafer

Preliminary Class

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